i,

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Welcome to STN International!
                               Enter x:
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LOGINID:ssspta1712jxr
PASSWORD:
TERMINAL (ENTER 1, 2, 3, OR ?):2
                      Welcome to STN International
                  Web Page URLs for STN Seminar Schedule - N. America
 NEWS
 NEWS
                  "Ask CAS" for self-help around the clock
 NEWS
         Feb 24
                  PCTGEN now available on STN
         Feb 24
 NEWS 4
                 TEMA now available on STN
 NEWS 5
         Feb 26 NTIS now allows simultaneous left and right truncation
 NEWS 6
         Feb 26 PCTFULL now contains images
     7
                  SDI PACKAGE for monthly delivery of multifile SDI results
 NEWS
         Mar 04
 NEWS 8
         Mar 24
                  PATDPAFULL now available on STN
 NEWS 9
         Mar 24
                  Additional information for trade-named substances without
                  structures available in REGISTRY
 NEWS 10
          Apr 11
                  Display formats in DGENE enhanced
 NEWS 11
         Apr 14
                  MEDLINE Reload
         Apr 17
 NEWS 12
                  Polymer searching in REGISTRY enhanced
 NEWS 13
          Jun 13
                  Indexing from 1947 to 1956 added to records in CA/CAPLUS
 NEWS 14
          Apr 21
                  New current-awareness alert (SDI) frequency in
                  WPIDS/WPINDEX/WPIX
 NEWS 15
          Apr 28
                  RDISCLOSURE now available on STN
 NEWS 16
          May 05
                  Pharmacokinetic information and systematic chemical names
                  added to PHAR
 NEWS 17
          May 15
                  MEDLINE file segment of TOXCENTER reloaded
 NEWS 18
         May 15
                  Supporter information for ENCOMPPAT and ENCOMPLIT updated
 NEWS 19
         May 19
                  Simultaneous left and right truncation added to WSCA
 NEWS 20
         May 19
                  RAPRA enhanced with new search field, simultaneous left and
                  right truncation
                  Simultaneous left and right truncation added to CBNB
 NEWS 21
          Jun 06
 NEWS 22
          Jun 06
                  PASCAL enhanced with additional data
 NEWS 23
         Jun 20
                  2003 edition of the FSTA Thesaurus is now available
 NEWS 24
         Jun 25
                 HSDB has been reloaded
 NEWS 25
         Jul 16
                  Data from 1960-1976 added to RDISCLOSURE
 NEWS 26
         Jul 21
                  Identification of STN records implemented
          Jul 21
 NEWS 27
                  Polymer class term count added to REGISTRY
 NEWS 28
         Jul 22
                  INPADOC: Basic index (/BI) enhanced; Simultaneous Left and
                  Right Truncation available
 NEWS 29
         AUG 05
                 New pricing for EUROPATFULL and PCTFULL effective
                  August 1, 2003
              April 4 CURRENT WINDOWS VERSION IS V6.01a, CURRENT
 NEWS EXPRESS
               MACINTOSH VERSION IS V6.0b(ENG) AND V6.0Jb(JP),
               AND CURRENT DISCOVER FILE IS DATED 01 APRIL 2003
 NEWS HOURS
               STN Operating Hours Plus Help Desk Availability
 NEWS INTER
               General Internet Information
 NEWS LOGIN
               Welcome Banner and News Items
NEWS PHONE
               Direct Dial and Telecommunication Network Access to STN
               CAS World Wide Web Site (general information)
```

Enter NEWS followed by the item number or name to see news on that

specific topic.

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FILE 'HOME' ENTERED AT 10:42:11 ON 11 AUG 2003

=> FIL REGISTRY
COST IN U.S. DOLLARS

SINCE FILE TOTAL ENTRY SESSION 0.21 0.21

COST IN U.S. DOLLARS FULL ESTIMATED COST

FILE 'REGISTRY' ENTERED AT 10:42:19 ON 11 AUG 2003 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2003 American Chemical Society (ACS)

Property values tagged with IC are from the ZIC/VINITI data file provided by InfoChem.

STRUCTURE FILE UPDATES: 8 AUG 2003 HIGHEST RN 563538-18-1 DICTIONARY FILE UPDATES: 8 AUG 2003 HIGHEST RN 563538-18-1

TSCA INFORMATION NOW CURRENT THROUGH JANUARY 6, 2003

Please note that search-term pricing does apply when conducting SmartSELECT searches.

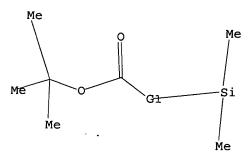
Crossover limits have been increased. See HELP CROSSOVER for details.

Experimental and calculated property data are now available. See HELP PROPERTIES for more information. See STNote 27, Searching Properties in the CAS Registry File, for complete details: http://www.cas.org/ONLINE/STN/STNOTES/stnotes27.pdf

Uploading 09937598.str

L1 STRUCTURE UPLOADED

=> d l1 L1 HAS NO ANSWERS L1 STR



G1 CH2, A, Cb, Cy, Hy, Id, Ak

Structure attributes must be viewed using STN Express query preparation.

=> s 11 sss sam

SAMPLE SEARCH INITIATED 10:42:51 FILE 'REGISTRY'
SAMPLE SCREEN SEARCH COMPLETED - 937 TO ITERATE

100.0% PROCESSED 937 ITERATIONS

29 ANSWERS

SEARCH TIME: 00.00.01

FULL FILE PROJECTIONS: ONLINE **COMPLETE**

BATCH **COMPLETE**

PROJECTED ITERATIONS: 16904 TO 2057 PROJECTED ANSWERS: 257 TO 90

L2 29 SEA SSS SAM L1

=> d scan

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

MF C13 H28 O3 Si

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

HOW MANY MORE ANSWERS DO YOU WISH TO SCAN? (1):28

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

IN 2-Pentenoic acid, 4-methyl-2-(trimethylsilyl)-, 1,1-dimethylethyl ester,
 (E)- (9CI)

MF C13 H26 O2 Si

Double bond geometry as shown.

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

L2 29 ANSWERS . REGISTRY COPYRIGHT 2003 ACS on STN

IN 3-Decenoic acid, 2-[(1R)-1-hydroxy-2-methylpropyl]-2-

[(trimethylsilyl)methyl]-, 1,1-dimethylethyl ester, (2R,3E)-rel- (9CI)

MF C22 H44 O3 Si

Relative stereochemistry.

Double bond geometry as shown.

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

IN Benzoic acid, 5-hexyl-4-(hydroxymethyl)-2-(trimethylsilyl)-,

1,1-dimethylethyl ester (9CI)

MF C21 H36 O3 Si

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

IN 1H-Imidazole-1-carboxylic acid, 4-iodo-2-(trimethylsilyl)-,

1,1-dimethylethyl ester (9CI)

MF C11 H19 I N2 O2 Si

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

IN 1(2H)-Pyridinecarboxylic acid, 3,6-dihydro-4-(trimethylsily1)-,

1,1-dimethylethyl ester (9CI)

MF C13 H25 N O2 Si

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN
IN 3-Pentenoic acid, 2-methylene-5-(trimethylsilyl)-, 1,1-dimethylethyl
 ester, (3Z)- (9CI)
MF C13 H24 O2 Si

Double bond geometry as shown.

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

Absolute stereochemistry.

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN
IN Carbamic acid, (trimethylsilyl)-, 1,1-dimethylethyl ester (9CI)
MF C8 H19 N O2 Si

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

IN 2-Nonen-8-ynoic acid, 9-(trimethylsilyl)-, 1,1-dimethylethyl ester, (E)(9CI)

MF C16 H28 O2 Si

Double bond geometry as shown.

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

IN 2-Propenoic acid, 3-(trimethylsilyl)-, 1,1-dimethylethyl ester, (E)- (9CI)

MF C10 H20 O2 Si

Double bond geometry as shown.

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

IN D-ido-Heptonic acid, 5-(acetylamino)-3,5,7-trideoxy-4-O-[(1,1dimethylethyl)dimethylsilyl]-7-(trimethylsilyl)-, 1,1-dimethylethyl ester
(9CI)

MF C22 H47 N O6 Si2

Absolute stereochemistry.

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

IN Carbamic acid, [1-(phenylmethyl)-2-[(trimethylsilyl)oxy]-2propenyl](trimethylsilyl)-, 1,1-dimethylethyl ester, (S)- (9CI)

MF C21 H37 N O3 Si2

Absolute stereochemistry.

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

1,1,3-Propanetricarboxylic acid, 2-(trifluoromethyl)-3-(trimethylsilyl)-,
3-(1,1-dimethylethyl) 1,1-diethyl ester, (R*,R*)- (9CI)

MF C18 H31 F3 O6 Si

Relative stereochemistry.

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN
IN 2-Heptenoic acid, 4-methyl-2-(trimethylsilyl)-, 1,1-dimethylethyl ester,
(Z)- (9CI)
MF C15 H30 O2 Si

Double bond geometry as shown.

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

MF C12 H27 O2 Si2 . Li

• Li+

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

IN Undecanoic acid, 2-[(R)-(dimethylphenylsilyl)iodomethyl]-3-hydroxy-2-(1E)-

1-octenyl-, 1,1-dimethylethyl ester, (2S,3S)-rel- (9CI)

MF C32 H55 I O3 Si

Relative stereochemistry.

Double bond geometry as shown.

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

IN 6-Azatricyclo[3.2.1.02,4]octane-6-carboxylic acid, 7-oxo-3-

(trimethylsilyl) -, 1,1-dimethylethyl ester, (1R,2S,3R,4S,5S)-rel- (9CI)

MF C15 H25 N O3 Si

Relative stereochemistry.

Absolute stereochemistry. Rotation (+).

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN
IN Bicyclo[2.2.1]hept-5-ene-2-carboxylic acid, 3-(trimethylsilyl)-,
1,1-dimethylethyl ester, polymer with trimethylsilyl 3(trimethylsilyl)bicyclo[2.2.1]hept-5-ene-2-carboxylate (9CI)

MF (C15 H26 O2 Si . C14 H26 O2 Si2)x

CI PMS

CM 1

CM 2

$$\begin{array}{c} O \\ \parallel \\ C-O-SiMe_3 \end{array}$$

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

MF C13 H26 O3 Si

Double bond geometry as shown.

L229 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN 2-Undecen-10-ynoic acid, 7-hydroxy-3-methoxy-4,4,6,8-tetramethyl-5-oxo-11-IN (trimethylsilyl)-, 1,1-dimethylethyl ester, (2Z,6R,7S,8S)-rel- (9CI) C23 H40 O5 Si MF

Relative stereochemistry. Double bond geometry as shown.

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

L229 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN 5-Thia-1-azabicyclo[4.2.0]oct-2-ene-2-carboxylic acid, IN 3-[(acetyloxy)methyl]-7-[(1,1-dimethylethyl)dimethylsilyl]-8-oxo-, 1,1-dimethylethyl ester, 5,5-dioxide, (6R,7S)- (9CI) C20 H33 N O7 S Si MF

Absolute stereochemistry.

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN Benzenepropanoic acid, .beta.-hydroxy-.beta.-(trimethylsilyl)-, L_2 IN 1,1-dimethylethyl ester (9CI)

C16 H26 O3 Si MF

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN
IN 1H-Pyrrole-1-carboxylic acid, 3-(trimethylsilyl)-4[(trimethylsilyl)ethynyl]-, 1,1-dimethylethyl ester (9CI)
MF C17 H29 N O2 Si2

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

Relative stereochemistry.

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

CM 1

CM 2

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN
IN 4-Pentynoic acid, 3-oxo-5-(trimethylsilyl)-, 1,1-dimethylethyl ester (9CI)
MF C12 H20 O3 Si

.

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

L2 29 ANSWERS REGISTRY COPYRIGHT 2003 ACS on STN

IN 2-Cyclopropene-1,1-dicarboxylic acid, 2,3-bis(trimethylsilyl)-,

bis(1,1-dimethylethyl) ester (9CI)

MF C19 H36 O4 Si2

PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

ALL ANSWERS HAVE BEEN SCANNED

=> s l1 sss full FULL SEARCH INITIATED 10:44:48 FILE 'REGISTRY' FULL SCREEN SEARCH COMPLETED - 18710 TO ITERATE 100.0% PROCESSED 18710 ITERATIONS

SEARCH TIME: 00.00.01

L3 508 SEA SSS FUL L1

=> FIL CAPLUS

COST IN U.S. DOLLARS

SINCE FILE

TOTAL

FULL ESTIMATED COST

ENTRY

SESSION

508 ANSWERS

149.75 149.96

FILE 'CAPLUS' ENTERED AT 10:45:20 ON 11 AUG 2003 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2003 AMERICAN CHEMICAL SOCIETY (ACS)

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FILE COVERS 1907 - 11 Aug 2003 VOL 139 ISS 7 FILE LAST UPDATED: 10 Aug 2003 (20030810/ED)

This file contains CAS Registry Numbers for easy and accurate substance identification.

- => S (SILSESQUIOXANE AND ORGANOSILSESQUIOXANE AND POLYSILSESQUIOXANE AND ORGANOPOLYSILSESQUIOXANE)
 - 3833 SILSESQUIOXANE
 - 6207 SILSESQUIOXANES
 - 6663 SILSESQUIOXANE

(SILSESQUIOXANE OR SILSESQUIOXANES)

- 61 ORGANOSILSESQUIOXANE
- 46 ORGANOSILSESQUIOXANES
- 92 ORGANOSILSESQUIOXANE

(ORGANOSILSESQUIOXANE OR ORGANOSILSESQUIOXANES)

- 314 POLYSILSESQUIOXANE
 - 215 POLYSILSESQUIOXANES
 - 401 POLYSILSESQUIOXANE

(POLYSILSESQUIOXANE OR POLYSILSESQUIOXANES)

- 6 ORGANOPOLYSILSESQUIOXANE
- 4 ORGANOPOLYSILSESQUIOXANES
- 8 ORGANOPOLYSILSESQUIOXANE

(ORGANOPOLYSILSESQUIOXANE OR ORGANOPOLYSILSESQUIOXANES)

0 (SILSESQUIOXANE AND ORGANOSILSESQUIOXANE AND POLYSILSESQUIOXANE AND ORGANOPOLYSILSESQUIOXANE)

- => S (SILSESQUIOXANE OR ORGANOSILSESQUIOXANE OR POLYSILSESQUIOXANE OR ORGANOPOLYSILSESQUIOXANE)
 - 3833 SILSESQUIOXANE
 - 6207 SILSESQUIOXANES
 - 6663 SILSESQUIOXANE

(SILSESQUIOXANE OR SILSESQUIOXANES)

- 61 ORGANOSILSESQUIOXANE
- 46 ORGANOSILSESQUIOXANES
- 92 ORGANOSILSESQUIOXANE

(ORGANOSILSESQUIOXANE OR ORGANOSILSESQUIOXANES)

L4

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314 POLYSILSESQUIOXANE
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215 POLYSILSESQUIOXANES

401 POLYSILSESQUIOXANE

(POLYSILSESQUIOXANE OR POLYSILSESQUIOXANES)

- 6 ORGANOPOLYSILSESQUIOXANE
- 4 ORGANOPOLYSILSESQUIOXANES
- 8 ORGANOPOLYSILSESQUIOXANE

(ORGANOPOLYSILSESQUIOXANE OR ORGANOPOLYSILSESQUIOXANES)

6743 (SILSESQUIOXANE OR ORGANOSILSESQUIOXANE OR POLYSILSESQUIOXANE OR ORGANOPOLYSILSESQUIOXANE)

=> s 13 and 15

L5

304 L3

L6 2 L3 AND L5

=> d 16 bib hitstr

L6 ANSWER 1 OF 2 CAPLUS COPYRIGHT 2003 ACS on STN

AN 1999:698181 CAPLUS

DN 131:315843

TI Carboxy- and hydroxy-pendent silicone compound, photoresist containing it, and its patterning

IN Nakajima, Mutsuo; Kaneko, Ichiro; Ishihara, Toshinobu; Tsuchiya, Junji; Hatakeyama, Jun; Nagura, Shigehiro

PA Shin-Etsu Chemical Industry Co., Ltd., Japan

SO Jpn. Kokai Tokkyo Koho, 95 pp. CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
		-			
ΡI	JP 11302382	A2	19991102	JP 1998-227633	19980728
	US 6309796	B1	20011030	US 1998-129950	19980806
	US 2002058205	A1	20020516	US 2001-887320	20010625
PRA1	JP 1997-224389	Α	19970806		
	JP 1998-52760	A	19980218		
	US 1998-129950	A3	19980806		
TΤ	152266-34-7				

IT 152266-34-7

RL: MOA (Modifier or additive use); USES (Uses)
 (carboxy- and hydroxy-pendent silsesquioxane-contg.
 photoresist and its patterning)

RN 152266-34-7 CAPLUS

CN Propanoic acid, 3,3'-(1,1,3,3-tetramethyl-1,3-disiloxanediyl)bis-, bis(1,1-dimethylethyl) ester (9CI) (CA INDEX NAME)

=> d 16 1-2 bib hitstr

L6 ANSWER 1 OF 2 CAPLUS COPYRIGHT 2003 ACS on STN

AN 1999:698181 CAPLUS

DN 131:315843

TI Carboxy- and hydroxy-pendent silicone compound, photoresist containing it, and its patterning

IN Nakajima, Mutsuo; Kaneko, Ichiro; Ishihara, Toshinobu; Tsuchiya, Junji;

Hatakeyama, Jun; Nagura, Shigehiro

Shin-Etsu Chemical Industry Co., Ltd., Japan PΑ

Jpn. Kokai Tokkyo Koho, 95 pp. SO

CODEN: JKXXAF

DT Patent

Japanese LA

באו כועד 1

FAN.	CNT I				
	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
ΡI	JP 11302382	A2	19991102	JP 1998-227633	19980728
	US 6309796	B1	20011030	US 1998-129950	19980806
	US 2002058205	A1	20020516	US 2001-887320	20010625
PRAI	JP 1997-224389	Α	19970806		
	JP 1998-52760	Α	19980218		
	US 1998-129950	A3	19980806		
TT	152266-34-7				

RL: MOA (Modifier or additive use); USES (Uses) (carboxy- and hydroxy-pendent silsesquioxane-contg. photoresist and its patterning)

152266-34-7 CAPLUS RN

CNPropanoic acid, 3,3'-(1,1,3,3-tetramethyl-1,3-disiloxanediyl)bis-, bis(1,1-dimethylethyl) ester (9CI) (CA INDEX NAME)

L6 ANSWER 2 OF 2 CAPLUS COPYRIGHT 2003 ACS on STN

AN1996:557390 CAPLUS

DN125:181341

Alkali-developable positive resist material ΤI

Takemura, Katsuya; Tsucha, Junji; Ishihara, Toshinobu; Tanaka, Haruyori; IN Kawai, Yoshio; Nakamura, Jiro

Shinetsu Chem Ind Co, Japan; Nippon Telegraph & Telephone PA

Jpn. Kokai Tokkyo Koho, 17 pp. so CODEN: JKXXAF

DT Patent

Japanese LA

FAN.	CNT 3				
	PATENT NO.	KIND	DATE	APPLICATION NO. DATE	E
ΡI	JP 08160605	A2 ·	19960621	JP 1994-331722 1994	41209
	JP 3094819	B2	20001003	•	
	TW 397936	В	20000711	TW 1995-84112843 1995	51201
	US 5612170	Α	19970318	US 1995-569659 1999	51208
PRAI	JP 1994-331720	Α	19941209		
	JP 1994-331721	Α	19941209		
	JP 1994-331722	Α	19941209		
OS	MARPAT 125:18134	1			

IT 152266-34-7P

> RL: PNU (Preparation, unclassified); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(alkali-developable silicone pos. resist material with high sensitivity and resoln.)

152266-34-7 CAPLUS RN

Propanoic acid, 3,3'-(1,1,3,3-tetramethyl-1,3-disiloxanediyl)bis-, CN bis(1,1-dimethylethyl) ester (9CI) (CA INDEX NAME)